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Density functional theory study into the adsorption of CO₂, H and CH_x (x = 0–3) as well as C₂H₄ on α -Mo₂C(0001)

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Abstract

The structures and energetics of the chemisorbed CO_2 , CH_x species and H as well as C_2H_4 on the α -Mo₂C(0001) surface have been computed at the GGA-RPBE level of density functional theory. It is found that CO_2 adsorbs dissociately into CO and O, in agreement with the experimental finding. The adsorbed O, CH_x and H species prefer the site of three surface molybdenum atoms over a second layer carbon atom (V_C site). On the basis of the calculated adsorption energies of CH_x and H, the sequential dehydrogenation of CH_4 and the C/C coupling reaction of CH_x have been discussed.

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Keywords: DFT; CO₂ adsorption; CH₄ sequential dehydrogenation; Molybdenum carbides

1. Introduction

Transition metal carbides have attracted significant attentions due to their unique physical and chemical properties like extreme hardness, high melting points and metallic conductivity [1]. It has been demonstrated that transition metal carbides have excellent catalytic activity in a wide variety of hydrogen-involved reactions [2–11], such as hydrocarbon synthesis from CO hydrogenation [3,12–15], dehalogenation [8], hydrodesulfurization [16,17] and hydrodenitrogenation [18,19].

 CH_4 dry reforming has received high attention, because it can convert these cheapest carbon containing materials into useful chemical products ($CH_4 + CO_2 = 2CO + 2H_2$). Supported group VIII noble metals like Ni, Pt, Ru and Rh are very active for this reaction at elevated temperatures,

but have the problem of deactivation due to carbon deposition. Moreover, these metals are expensive and not available in large amounts [20]. The most frequently used commercial catalyst is the α -alumina supported nickel [21], but the problem is the deactivation caused by coke formation from CH₄ decomposition (C + 2H₂) and CO disproportionation (C + CO₂). Compared to steam reforming (CH₄ + H₂O = CO + 3H₂), CH₄ dry reforming has the advantages of producing synthesis gas at a low H₂/CO ratio, which is suitable for higher hydrocarbons in Fischer–Tropsch synthesis.

As an active catalyst for steam reforming, dry reforming and water gas shift $(H_2O + CO = CO_2 + H_2)$, molybdenum carbides have attracted significant interest as potential substitutes for these precious noble metals and conventional nickel-based catalysts [22–26] due to their similar behaviors in surface catalysis [27]. In addition, a new catalytic application of molybdenum carbides has recently been established in the non-oxidative catalytic transformation of CH_4 , e.g., $MoO_3/ZSM-5$ was proved to be the catalyst for benzene formation in this reaction [28–34]. Further studies revealed that MoO_3 is transformed into Mo_2C with CH_4 at

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high-temperature. It was found that Mo₂C in combination with ZSM-5 zeolite effectively catalyzes the aromatization of CH₄ with 80% selectivity at about 10–15% conversion [31–34]. Since this reaction has been observed neither on pure Mo₂C nor ZSM-5 alone, it was thought that the role of Mo₂C is the activation of CH₄ to yield CH₃ and CH₂ radicals with a certain lifetime on Mo₂C to couple into C₂H₄ [35]. The formed C₂H₄ can be oligomerized and aromatized on the acidic sites of ZSM-5. Under ultra-high-vacuum (UHV) condition it has been found that CH₃ and CH₂ radicals on Mo₂C/Mo(100) can combine into C₂H₄. Further works disclosed that Mo₂C/ZSM-5 is an active catalyst for the aromatization of the other lower alkanes, such as ethane [36], propane [37], *n*-butane and *iso*-butane [38].

Transition metal carbides are formed by substituting the lattice oxygen atoms of oxides by carbon atoms. The insertion of carbon atoms into Mo lattice causes the contraction of the d-band. Even with fewer electrons, the band is filled to a greater extent and the density of states at the Fermi level is close to those of the Group VIII noble metals [20,21], the center of d-band of which is closer to the Fermi level. Hammer and Nørskov [39] as well as others [40] have shown that the important surface parameters for the reactivity are the position of the whole d-bands relative to the Fermi level, which determines both the size of the bonding and anti-bonding energy shifts, and the degree of filling the anti-bonding states. Molybdenum carbides, in particular, are active and stable for hydrocarbon reforming and resistant to deactivation by SO_x poisoning or coking. Although these carbides exhibit a very good catalytic performance in these reactions, substantial fundamental understanding on catalytic nature and adsorption characters is not well established.

Over the past years, quantum chemical methods have become new tools for understanding the structures and stability as well as reactivity of active catalyst surfaces. With recent improvements in quantum chemistry, density functional theory methods (DFT) are capable of providing qualitative and, in many cases, quantitative insights into relationship between surface structures and catalytic activity. In this paper, we present a detailed DFT study of CO_2 , H, CH_x (x=0–3) species and C_2H_4 adsorption on α -Mo₂C(0001) in order to get the insight into their surface and structure properties.

2. Methods and models

All DFT calculations were carried out with the DMol³ [41] program package in Materials Studio of Accelrys Inc. [42]. In DMol³, the physical wave functions are expanded in terms of accurate numerical basis sets. We used the double-numeric quality basis set with polarization functions, and the semi-core pseudopotential was used for Mo atom [43]. The generalized gradient approximation (GGA) with the revised Perdew–Burke–Ernzerhof functional (RPBE) [44] was utilized. The RPBE functional

usually gives absolute errors in adsorption energy of about 0.2 eV [44,45]. A Fermi smearing of 0.0005 a.u. (0.0136 eV) and a real-space cutoff of 5.5 A were used to improve the computational performance. For numerical integration, the medium quality mesh was used, i.e. the convergence criteria for structure optimization and energy calculation were set to (1) SCF tolerance of 1×10^{-5} a.u./ atom, (2) energy tolerance of 2.0×10^{-5} a.u./atom, (3) maximum force tolerance of 4.0×10^{-3} a.u./Å and (4) maximum displacement tolerance of 5.0×10^{-3} Å, respectively. Larger sets of k points were selected (4 or 16) for the case of the bulk α -Mo₂C(0001) surfaces, making sure that there is no significant change in the calculated energies when a larger number of k points was used. On the basis of CO_2 adsorption, we have tested different real-space cutoffs (5.5 Å vs. 6.0 Å), smearing values (0.0005 a.u. vs. Fermi level), and integration meshes (medium vs. fine). The differences in adsorption energy are 0.01, 0.008 and 0.06 eV, respectively. Therefore we used the real-space cutoffs of 5.5 Å and the smearing of 0.0005 a.u. as well as the medium quality meshes in our work. The complete linear synchronous transit and quadratic synchronous transit (LST/QST) method was used to locate the transition states. The validity of these methods has been proved [46].

A $p(2\times2)$ unit cell with a slab of four-layer thickness (2Mo+2C) was used to describe these small molecules adsorption on $\alpha\text{-Mo}_2\text{C}(0001)$, corresponding to 1/4 ML coverage. The adsorbed species and the three top layers (2Mo+1C) of $\alpha\text{-Mo}_2\text{C}(0001)$ were allowed to relax, while only the bottom layer (1C) was fixed at the calculated bulk lattice position in geometry optimization. In addition, for atomic H, and C as well as the open-shell molecular CH_x , the spin-unrestricted approach is used.

All geometrics were optimized without symmetry constraints. Adsorption energy is computed by subtracting the energies of the gas phase species and the surface from the energy of the adsorbed system as shown in Eq. (1): $E_{\rm ads} = E({\rm adsorbate/slab}) - E({\rm adsorbate}) - E({\rm slab}).$ With this definition, a negative E_{ads} corresponds to stable adsorption on the surface. For CH₄ dissociation into CH_x and H on the surface, the dissociation energy is defined as the difference between the sum of CH_x and H adsorption, and the sum of bare slab and free CH₄, $\Delta E_{\text{diss}} = [E(\text{CH}_x/\text{slab}) +$ $(4 - x)E(H/slab) + xE(slab) - [E(CH_4) + 5E(slab)],$ i.e.; negative ΔE_{diss} means exothermic dissociation, while positive $\Delta E_{\rm diss}$ endothermic dissociation. Mulliken population analysis was carried out to estimate the partial charge on the adsorbed molecule or fragment for examining the qualitative trends in charge redistribution.

3. Results and discussion

3.1. Structure of α -Mo₂C

As a representative carbide phase, α -Mo₂C has an orthorhombic crystal structure with Mo atoms slightly distorted from their positions in close-packed planes and

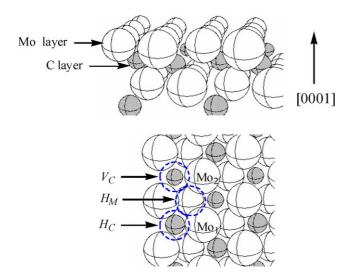


Fig. 1. Top and side views of the un-relaxed α -Mo₂C(0001). Mo₁ and Mo₂ indicate Mo atom coordination with two and one C atoms, respectively. White ball indicates Mo atoms, and gray ball denotes C atoms.

carbon atoms occupying ordered positions in lattice octahedral vacancies. This has resulted in many reports referring to the closest-packed surface as the (0001) surface [47]. In our previous work [48], the DFT calculated lattice constants for the bulk α -Mo₂C (a=4.748 Å, b=6.026 Å and c=5.204 Å) are close to the experimental values (a=4.729 Å, b=6.028 Å and c=5.197 Å) [47]. The structure of α -Mo₂C perpendicular to the [0001] direction includes a series of alternating Mo and C atom layers. As shown in Fig. 1, there are two individual Mo atoms (Mo₁ and Mo₂) with different carbon coordination numbers on the Mo-terminated surface. Mo₁ coordinates with two car-

bon atoms of the sublayer and Mo_2 coordinates with one carbon atom of the sublayer. In comparison with the bulk Mo atom, Mo_1 has one coordination vacancy and Mo_2 has two coordination vacancies. Our focus is the Mo-terminated site, which is very important for the catalytic activity and the catalytic reactions occur mainly on it [16–19]. In our previous work [48], we have found that the C-terminated surface has also activity for oxygen and CO adsorption, but their adsorption energies (-5.36 and -1.74 eV) are much lower than those on the Mo-terminated surface (-8.46 and -2.23 eV). In addition, the computed CO_2 adsorption energy on the C-terminated surface ($p(2 \times 2)$ super cell) of -0.12 eV is lower than that (-2.38 eV) on the Mo-terminated surface. So the C-terminated surface is not considered in present work.

3.2. CO_2 adsorption on α - $Mo_2C(0001)$

As shown in Fig. 1, there are three different three-fold hollow sites on the Mo-terminated surface for adsorption: (i) three surface Mo atoms over a second layer carbon atom ($V_{\rm C}$ site), (ii) three surface Mo atoms over a second layer Mo atom ($H_{\rm M}$ site), (iii) three surface Mo atoms over a first layer carbon atom ($H_{\rm C}$ site), respectively. The possible top and bridge sites were also considered. All initial orientations on different sites of α -Mo₂C(0001) were considered, but only five structures (1–5) of chemisorbed CO₂ at 1/4 ML coverage were found as stable surface forms, as shown in Fig. 2. The calculated adsorption energies and bond parameters as well as the net charges of the chemisorbed CO₂ on α -Mo₂C(0001) are listed in Table 1.

As given in Table 1, 1 is the most stable adsorbed surface structure with the largest adsorption energy (-2.38 eV), while 2-5 have much lower adsorption energies

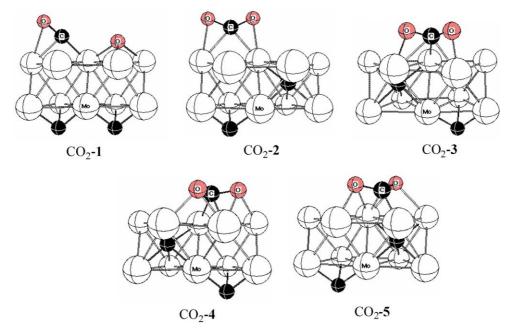


Fig. 2. Surface structures of CO_2 adsorption on the Mo-terminated $\alpha\text{-Mo}_2C(0001)$.

Table 1 The calculated geometric parameters (d, Å and θ , degree), adsorption energies (E_{ads} , eV) and the net charge (q) of CO₂ on α -Mo₂C(0001)

	$E_{ m ads}$	$d_{\mathrm{O-C}}$	$d_{ m C-Mo}$	$d_{\mathrm{O-Mo}}$	$\theta(O_1CO_2)$	q
CO ₂ –1	-2.38	1.233	1.997, 2.281	1.993-2.109	144.06	-1.014^{a}
CO ₂ –2	-0.54	1.250, 1.264	2.249, 2.341	2.254, 2.288	135.09	-0.291
CO_2 -3	-0.45	1.363, 1.312	2.185, 2.388	2.059, 2.166	117.57	-0.557
CO ₂ -4	-0.16	1.368, 1.371	2.108, 2.196	2.273, 2.328	112.03	-0.635
CO_2 –5	-0.14	1.355, 1.367	2.172, 2.255	2.288, 2.291	111.84	-0.589
CO_2		1.179			180.00	0.0

^a The sum of adsorbed CO (-0.285) and O (-0.729).

(-0.54 to -0.14 eV). In 1, CO₂ dissociates spontaneously into CO and O during optimization. The formed O atom locates at the $V_{\rm C}$ site and forms three Mo–O bonds with an averaged length of 2.051 Å. The formed CO bridges two adjacent Mo of V_C site and the C=O bond is elongated compared with free CO₂ (1.233 Å vs. 1.179 Å). This result agrees very well with the experimental finding that CO₂ dissociates on Mo₂C, and the formed atomic oxygen migrates into the bulk and the CO is desorbed during temperature-programmed desorption (TPD) [25,49], leaving a coordinatively unsaturated site available for another CO₂ coordination. In our previous work [48], on the Mo-terminated surface, both CO and O also prefer to chemisorb on the $V_{\rm C}$ sites with chemisorption energies of -2.23 and -4.39 eV (relative to $O_2/2$), respectively. The rather lower chemisorption energy of CO compared to atomic oxygen confirms the TPD observation.

For 2–5, CO₂ adsorbs activated but not dissociated. In 2 $(V_{\rm C} \text{ sites})$, CO₂ interacts with two adjacent Mo atoms via two C=O bonds and forms two Mo-C bonds, and the C-O bonds are elongated to 1.250 and 1.264 Å. In 3, CO₂ interacts with three Mo atoms on the surface by occupying one $H_{\rm M}$ site and the carbon center caps three Mo atoms with the formation of three Mo-C bonds, and each of the oxygen atoms interacts with the adjacent Mo atom, and the C-O bonds are elongated to 1.312 and 1.363 Å. In 4, CO₂ interacts with four Mo atoms by occupying one $H_{\rm M}$ site and one $V_{\rm C}$ site, and the carbon center bridges the adjacent Mo atoms to form two Mo-C bonds. Each of oxygen of CO₂ in 4 interacts with two surface Mo atoms, and the C-O bonds are elongated to 1.368 and 1.371 Å. In 5, CO₂ located on one $H_{\rm M}$ site and one $H_{\rm C}$ site. Each of oxygen in CO₂ in 5 interacts with two surface Mo atoms and the C–O bonds are elongated to 1.355 and 1.367 Å. For 2–5, the adsorbed CO₂ moiety has bent structure with an OCO angle of about 111°.

Apart from the structures and energies, it is also interesting to look into the change of the charges of CO_2 . The net charges of the chemisorbed CO_2 on α -Mo₂C(0001) are given in Table 1, compared with those of free CO_2 . It clearly shows that the chemisorbed CO_2 molecules are partially negative charged (-0.589 for 5 to -0.291 for 2), indicating the electron transfer from the α -Mo₂C(0001) surface into CO_2 . The same phenomena are found for chemisorbed CO_2 on Ni surfaces [50]. Freund and Messmer [51] suggested that the bending mechanism of the partially

negative charged $CO_2^{\delta-}$ is due to the effect of electrons transfer from surface into the anti-bonding orbital of CO_2 . Therefore the best and most appropriated description of CO_2 on the surface should be $CO_2^{\delta-}$.

Generally CO₂ activation on transition metal surfaces is structure sensitive, i.e.; different surface has different activation. For example, CO₂ adsorbs dissociatively on Fe(111), Fe(100) and Ni(110), but non-dissociativly on Fe(100) and Ni(111), while dissociativly and non-dissociativly on Ni(100) [50]. It also showed that CO₂ adsorbs dissociatively on clean Mo(100) [52] and polycrystalline Mo [53] at the lower temperature. It was believed that on Ni(110), Ni(100) and Fe(111) the chemisorbed $CO_2^{\delta-}$ anionic species represents an intrinsic precursor for CO2 dissociation into CO and atomic oxygen [54,55]. Nassir and Dwyer [56] found that CO₂ is strongly chemisorbed on Fe(100) and undergoes sequential C-O bond cleavage, and proposed that CO₂ dissociates in two steps with an intermediate complex composed of atomic oxygen and π bonded CO. Choe et al. [55] calculated the structures of the reaction intermediates, using the first CO bond breaking in carbon dioxide on Pt(111) and Fe(111), and the reaction intermediate complex is regarded as a possible intermediate complex model, which is formed in a CO oxidation reaction.

3.3. CH_x and H adsorption on α - $Mo_2C(0001)$

CH₄ decomposition on the surface results in the formation of CH_x (x = 0–3) and adsorbed hydrogen, so the adsorption energies of the dissociated species bear an essential implication in CH₄ dissociation. Now we analyze the adsorption of CH_x species and H on α -Mo₂C(0001).

For CH₃, the top, bridge and 3-fold hollow adsorption sites are considered. As shown in Fig. 3, there are only three favorable adsorption structures on α -Mo₂C(0001), CH₃($V_{\rm C}$) 6, CH₃($H_{\rm M}$) 7 and CH₃($H_{\rm C}$) 8. In 6–8, CH₃ has a η^3 capping model with three surface Mo atoms at different active sites ($V_{\rm C}$, $H_{\rm M}$, and $H_{\rm C}$ site), and the three C–H bonds point to the nearest neighbor atoms in favor of the eclipsed conformation. The calculated structural and energetic parameters are listed in Table 2.

In 6, the carbon atom is 1.506 Å above the surface and the C-Mo distances are 2.331, 2.401 and 2.405 Å, respectively. In 7, the carbon atom is located 1.508 Å above the surface and C-Mo distances are 2.382, 2.419 and

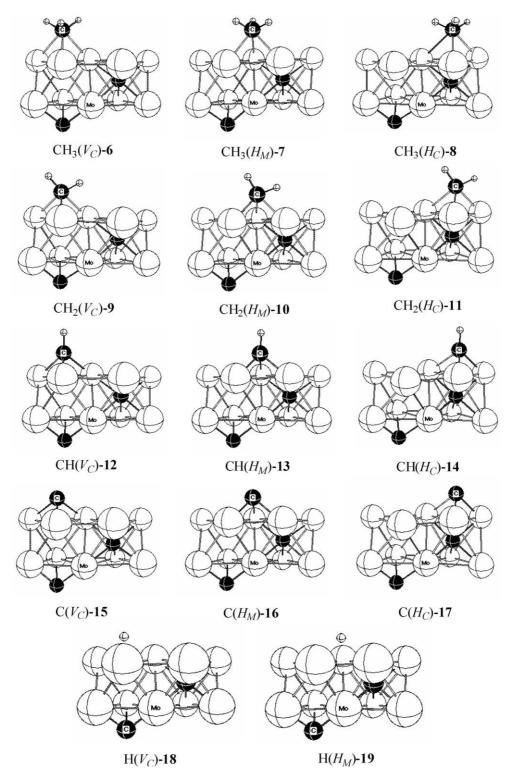


Fig. 3. Surface structures of CH_x species adsorption on the Mo-terminated α-Mo₂C(0001).

2.454 Å, respectively. In **8**, the carbon atom is 1.509 Å above the surface, and C–Mo distances are 2.365, 2.465 and 2.625 Å, respectively. As given in Table 3, **6** is the most stable structure for CH₃ adsorption on α -Mo₂C(0001) with a chemisorption energy of -2.37 eV, while **7** and **8** are less stable than **6** by about 0.34 and 0.50 eV, respectively.

Alike CH₃, CH₂ also has three stable adsorption structures CH₂($V_{\rm C}$) 9, CH₂($H_{\rm M}$) 10, and CH₂($H_{\rm C}$) 11, as shown in Fig. 3. In 9, one H atom near the top site has a C–H bond length of 1.131 Å, while the other H atom pointing midway between two neighboring Mo atoms has a C–H bond of 1.086 Å. In addition, the H–C–H angle is reduced from 135° of the isolated CH₂ radical to 101.9°. In 10 and

Table 2 The calculated geometric parameters (d, Å and θ , degree), chemisorption energies (E_{ads} , eV) and charges (q, e) of CH_x and H chemisorbed on α -Mo₂C(0001)

Adsorbate	$E_{ m ads}$	$d_{\mathrm{Mo-C}}\left(d_{\mathrm{H-Mo}}\right)$	$d_{\mathrm{C-H}}$	$\theta_{ m HCH}$	q
CH ₃ (doublet)			1.082	120.0	
$CH_3(V_C)$ -6	-2.37	2.331, 2.401, 2.405	1.100, 1.101, 1.102	104.1, 104.5, 104.7	-0.065
$CH_3(H_M)-7$	-2.03	2.382, 2.454, 2.419	1.094, 1.109, 1.100	103.5, 104.7, 104.8	-0.046
$CH_3(H_C)$ -8	-1.87	2.365, 2.465, 2.625	1.090, 1.097, 1.109	104.1, 104.6, 105.7	-0.053
CH ₂ (triplet)			1.081	135.5	
$CH_2(V_C)-9$	-4.37	2.156, 2.215, 2.252	1.086, 1.131	101.9	-0.309
$CH_2(H_M)-10$	-4.19	2.173, 2.238, 2.255	1.083, 1.146	98.9	-0.237
$CH_2(H_C)$ –11	-3.84	2.161, 2.227, 2.416	1.084, 1.132	101.6	-0.220
CH (doublet)			1.120		
CH(V _C)-12	-6.61	2.039, 2.094, 2.202	1.089		-0.482
$CH(H_{M})-13$	-6.44	2.060, 2.120, 2.176	1.085		-0.409
$CH(H_{C})-14$	-6.05	2.097, 2.102, 2.222	1.085		-0.370
$C(V_C)$ -15	-7.25	1.964, 2.005, 2.041			-0.534
$C(H_{M})-16$	-6.98	2.013, 2.022, 2.033			-0.437
$C(H_C)$ –17	-6.30	2.013, 2.058, 2.088			-0.416
H(V _C)-18	$-3.09 (-0.81)^{a}$	1.971, 2.016, 2.023			-0.106
H(H _M)-19	$-2.96 (-0.67)^{a}$	1.998, 2.059, 2.084			-0.052

^a The chemisorption energy of H relative to $1/2H_2$, $E_{ads}(H) = E(H/slab) - [1/2E(H_2) + E(slab)]$

Table 3 The calculated geometric parameters (d, and Å), adsorption energies (E_{ads} , eV) and charges (q, e) of C and H of ethylene on α -Mo₂C(0001)

Adsorbate	$E_{ m ads}$	d(C-Mo)	d(C–H)	d(C-C)	q(C)	q (H)
Eth(<i>H</i> _M)– 20	-1.13	2.301, 2.274 2.476, 2.511	1.08–1.110	1.474	-0.311,-0.338	0.154-0.172
Eth-Tilited (V _C)–21	-1.02	2.335, 2.339 2.429, 2.392	1.076–1.119	1.465	-0.245, -0.426	0.141-0.186
Eth($V_{\rm C}$)– 22	-0.91	2.302, 2.314 2.443, 2.477	1.076–1.120	1.445	-0.286, 0.289	0.154-0.169
$Eth(H_{M})$ –23	-0.89	2.262, 2.256 2.447, 2.524	1.077–1.113	1.454	-0.298, -0.300	0.151-0.165
C_2H_4			1.094	1.342	-0.168, -0.168	0.084, 0.084

11, the H atom near the top site has C-H bond length of 1.146 and 1.132 Å, respectively, and the H-C-H angles are 98.9° and 101.6°. As given in Table 2, 9 is the most stable structure for CH₂ adsorption with chemisorption energy of -4.37 eV, while 10 and 11 are less stable than 9 by 0.18 and 0.53 eV, respectively. It is to note that CH₂ adsorption is about two times stronger than CH₃ on the same site.

For CH adsorption, there are also three stable structures $CH(V_C)$ 12, $CH(H_M)$ 13 and $CH(H_C)$ 14, as shown in Fig. 3. In all cases, the C-H bond is almost perpendicular to the Mo-terminated α -Mo₂C(0001) surface. The most stable adsorption structure is 12 with an adsorption energy of -6.61 eV, while 13 and 14 are less stable (-6.44 and -6.05 eV, respectively). It is to note that CH adsorption is about three times stronger than CH₃ on the same surface.

For carbon atom, only three stable adsorption structures are found, $C(V_C)$ **15**, $C(H_M)$ **16** and $C(H_C)$ **17**. The most stable adsorption structure is **15** with an adsorption energy of -7.25 eV, while **16** and **17** are less stable (-6.98 and -6.30 eV, respectively). Thus, carbon atom

prefers to the $V_{\rm C}$ site, which is similar to C-terminated α -Mo₂C(0001) surface [57].

In addition, the adsorption of H atom on α -Mo₂C(0001) was investigated. All possible adsorption sites on the Mo-terminated surface were considered. Adsorption on the top and bridge sites did not exist during optimization structures. The adsorption energies are listed in Table 2. It is found that H atom adsorbs more strongly on the V_C site (H(V_C) 18) than on the H_M site (H(H_M) 19) with an adsorption energy of -0.81 and -0.67 eV, respectively. It is interesting to note that H atom is unstable on the H_C site with a C atom directly below them. During structure optimization, the H atom spontaneously shifts from the H_C site to H_M or V_C site. One might expect that H atom could occupy the H_C site at higher coverage, but this is beyond the scope of this study.

The most stable adsorption site determined for CH_x (x = 0–3) chemisorption on α -Mo₂C(0001) is the V_C site. Adsorption on the surface results in a net transfer of electrons to the adsorbate in all cases, the magnitude of which decrease with a decrease in the valence of the species. For

example, the net charge of CH is -0.482 on the adsorbate, while those of CH₂ and CH₃ are -0.309 and -0.065, respectively. This trend may be related to the increased population of the adsorbate valence orbitals, which are involved in the formation of the adsorbate–substrate bond [20b].

3.4. CH_4 sequential dehydrogenation

In gas phase, CH₄ sequential dehydrogenation is highly endothermic, and the computed energies are 4.68, 4.89, 4.67 and 3.66 eV for each step, which means that a total of 17.90 eV is needed for the complete dehydrogenation. On the basis of the calculated most stable CH_x (x = 0-3) species and H atom on α -Mo₂C(0001), the energy scheme of dehydrogenation is shown in Fig. 4. On α -Mo₂C(0001), there is significant reduction in the dissociation energy, owing to the presence of the strong Mo-CH_x and Mo-H bonds. It is to note that all individual steps are endothermic, and CH₄ dissociation into CH₃ and H is the most difficult step (0.73 eV), and the total reaction energies of CH₄ complete dehydrogenation is 1.67 eV. Therefore, a complete dissociation of CH₄ into surface C and H is very hard. Due to their importance in Fischer–Tropsch synthesis, the structure and stability of the surface species CH₃ have been studied intensively by means of theoretical and experimental methods, and CH has been identified as the most stable intermediate on the Pt metals surface [20]. On α - $Mo_2C(0001)$, however, adsorbed carbon is the most stable surface species as indicated by the calculated adsorption energy in Table 2.

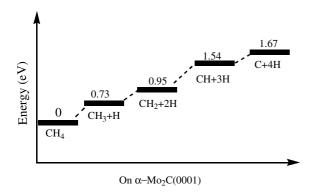


Fig. 4. Thermodynamic energetic scheme of CH_4 sequential dehydrogenation system.

3.5. C_2H_4 adsorption on α - $Mo_2C(0001)$

As an intermediate for the direct conversion of CH_4 into benzene, ethylene is investigated. The exact knowledge of the adsorption mode of ethylene on transition metal surfaces is of importance for the understanding of catalytic reactions involving this small olefin. Numerous experimental studies of the adsorption of ethylene on a variety of transition metal surfaces have been reported. The calculated structures and energies of ethylene adsorption on Mo-terminated α -Mo₂C(0001) are given in Fig. 5 and Table 3, respectively.

In 20, ethylene locates in the $H_{\rm M}$ site which is adjacent to two $V_{\rm C}$ sites with C–C bond length of 1.474 Å, and the C–C bond is slightly elongated by 0.132 Å compared with free ethylene. The optimized C–H bonds are bent away from the surface plane by 45.8°. In 21, ethylene adsorbs aslant at the $V_{\rm C}$ site, which is oriented with its C–C axis on average at an angle of 47.1° of Mo-terminated α -Mo₂C(0001) and the computed C–C bond length is 1.465 Å. In 22 and 23, ethylene adsorbs at the $V_{\rm C}$ site adjacent to two $H_{\rm M}$ sites and at the $H_{\rm M}$ site adjacent to two $H_{\rm C}$ sites. The C–C bond lengths to free ethylene are elongated about 0.102 and 0.108Å, respectively. On α -Mo₂C(0001), 20 is the most stable adsorbed structure on the Mo hollow site ($H_{\rm M}$ site, -1.13 eV), while 21, 22 and 23 are higher in energy (-1.02, -0.91, and -0.89 eV, respectively).

3.6. CH_x coupling reaction on α - $Mo_2C(0001)$

It has long been believed that alkyl chain growth in Fischer–Tropsch catalysis on metal surfaces proceeds by CH_x (C/C) coupling [58]. The prototypical C/C coupling

Table 4 Calculated barriers (E_a) and reaction energies (ΔE_r) for C/C coupling on α -Mo₂C(0001)

Coupling reaction	E _a (eV)	$\Delta E_{\rm r} \ ({\rm eV})$
$CH_3 + CH_3 \rightarrow CH_3CH_3$	4.28	0.87
$CH_3 + CH \rightarrow CH_3CH$	2.13	0.77
$CH_3 + CH_2 \rightarrow CH_3CH_2$	1.89	0.49
$CH_2 + CH_2 \rightarrow CH_2CH_2$	1.31	0.17
$CH_2 + CH \rightarrow CH_2CH$	0.97	-0.25
$CH + CH \rightarrow HCCH$	1.01	-0.32

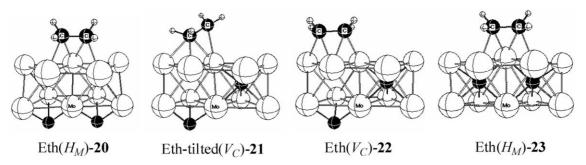


Fig. 5. Surface structures of ethylene adsorption the Mo-terminated α -Mo₂C(0001).

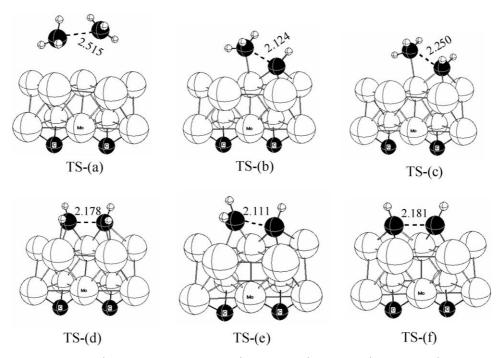


Fig. 6. Structures of transition state for C/C coupling reaction: (a) CH₃/CH₃, (b) CH₃/CH, (c) CH₃/CH₂, (d) CH₂/CH₂, (e) CH₂/CH and (f) CH/CH.

reaction has many possibilities: CH/CH, CH/CH₂, CH/ CH₃, CH₂/CH₂, CH₂/CH₃ and CH₃/CH₃. The calculated C/C coupling barriers (E_a) and reaction energies (ΔE_r) are given in Table 4. It is clearly to see that all the C/C coupling reactions are disfavored. The highest barrier is found for CH₃/CH₃ (4.28 eV), and this is associated with the valence of the adsorbed radical on the surface. On the basis of CH₃, CH₂, and CH adsorption, we have studied the adsorbate-adsorbate interaction at the increased coverage by comparing the adsorption energies of these species at the 1/2 ML and 1/4 ML. For the most stable adsorption site ($V_{\rm C}$ site), the adsorption energy differences between 1/2 ML and 1/4 ML are 0.03 eV for CH₃, 0.09 eV for CH₂, and 0.07 eV for CH. These results indicate that adsorbed species at the 1/2 ML show relatively weak lateral repulsion (see Fig. 6).

Our calculation shows that CH₃ is an unfavorable species for C/C coupling with high barriers (the activation energies are 4.28, 2.13 and 1.89 eV for CH₃/CH₃, CH₃/ CH and CH₃/CH₂, respectively), and this is consistent with the work of others [58b]. CH₂/CH₂ coupling is also unfavorable with an activation energy of 1.31 eV to yield adsorbed ethylene. In addition, CH/CH and CH/CH₂ couplings have rather lower barriers (1.01 and 0.97 eV, respectively), and they are kinetically competitive. Compared to CH₂/CH₂ coupling to form ethylene, CH/CH₂ coupling to form adsorbed vinyl radical has lower barrier (1.31 vs. 0.97 eV). This suggests that direct CH₂/CH₂ coupling should be less possible at low coverage. Furthermore that lower barrier of CH/CH coupling to form acetylene on the surface shows the special role of CH, which might be directly associated with the aromatization process of CH₄. A recent experimental work [59] also concluded that

the principal route for the aromatization of CH_4 is the formation of C_2H_2 over Mo_2C and the role of ZSM-5 is very likely to promote the reactions of C_2H_2 (oligomerization and aromatization) migrated from Mo_2C into ZSM-5.

4. Conclusion

The adsorption behaviors of CO_2 , CH_x species, H and C_2H_4 on α -Mo₂C(0001) were investigated at the GGA-RPBE level of density functional theory. The main subjective of this study is the structures and energetics of the adsorbed surface species, which are directly associated with the mechanism of Fischer–Tropsch synthesis. In agreement with the experimental observation, CO_2 dissociates spontaneously on the Mo surface, and the formed O locates at three surface Mo atoms over a second layer carbons atom (V_C site), and the formed CO bridges two surface Mo atoms of the V_C site. Other adsorption structures have only activated CO_2 and are less stable.

Energetically, the CH_x species and atomic H adsorb strongly at the preferred site (V_C site), which are similarly to oxygen adsorption on the same surface. The chemisorption energy of CH_x increases with their increasing number of the valence orbitals in the order of $CH_3 < CH_2 < CH < C$. Compared with gas-phase CH_4 dissociation, adsorbed CH_4 has much lower, but still endothermic dehydrogenation energies.

Furthermore, the C/C coupling of the adsorbed CH_x species has also been computed. The calculated activation energy decreases with the increasing number of the valence orbitals. The low activation energies of the CH/CH, CH₂/CH and CH₂/CH₂ coupling reactions might reveal the role of the surface C₂H₂, CH₂CH and C₂H₄, which might be

directly associated with the aromatization process of CH₄ or other lower alkanes.

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